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Serial No.: 10/709,776

Conf. No.: 3775

Filing Date: 05/27/2004

Art Unit: 2811

Applicant: William G. America

Examiner: IM, Junghwa M.

Title: SEMICONDUCTOR DEVICE
FORMED BY IN-SITU MODIFICATION
OF DIELECTRIC LAYER AND
RELATED METHODSDocket No.: FIS920040083US1
(IBMF-0058)

COMMISSIONER FOR PATENTS

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Response to Restriction Requirement in 7 pages

in the above identified application.

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In Re Application of: William G. America

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Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

Sir:

I. INTRODUCTORY COMMENTS

This paper is being filed in response to the Restriction Requirement dated September 22, 2005. Applicant hereby provisionally elects Group I, claims 1-7, with traverse.